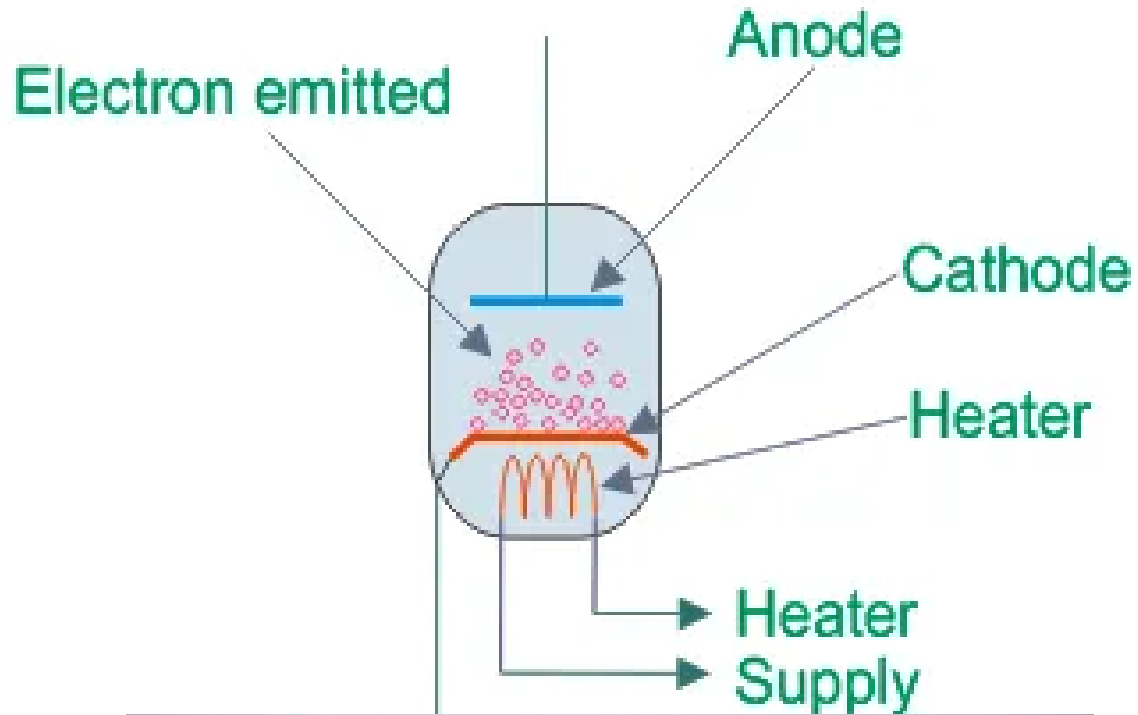
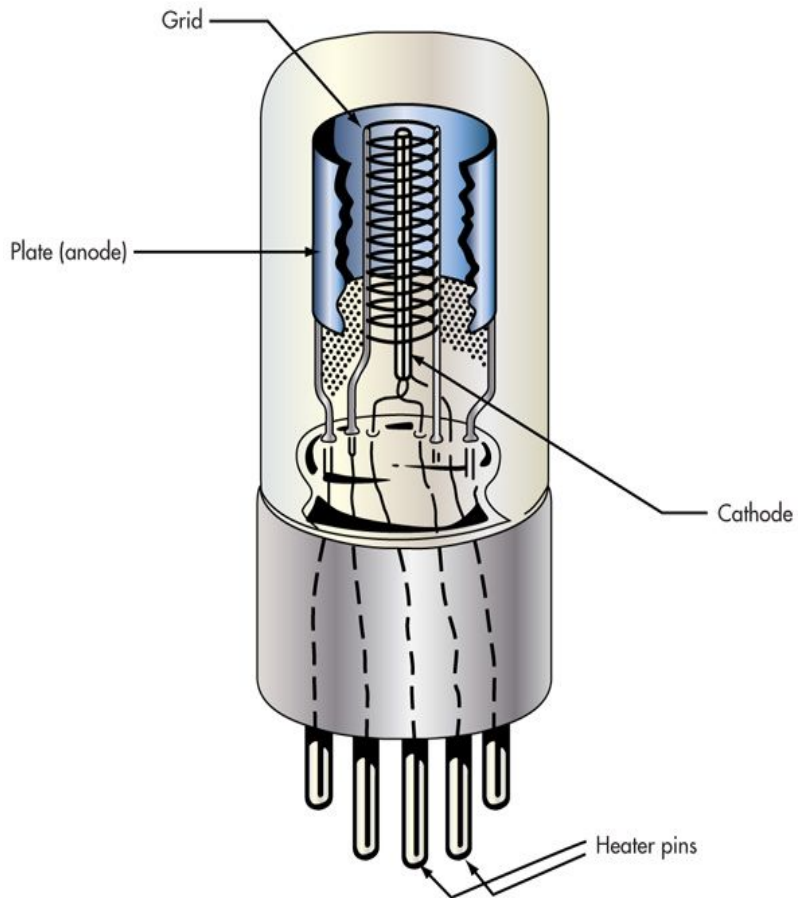


# **Analog Electronics**

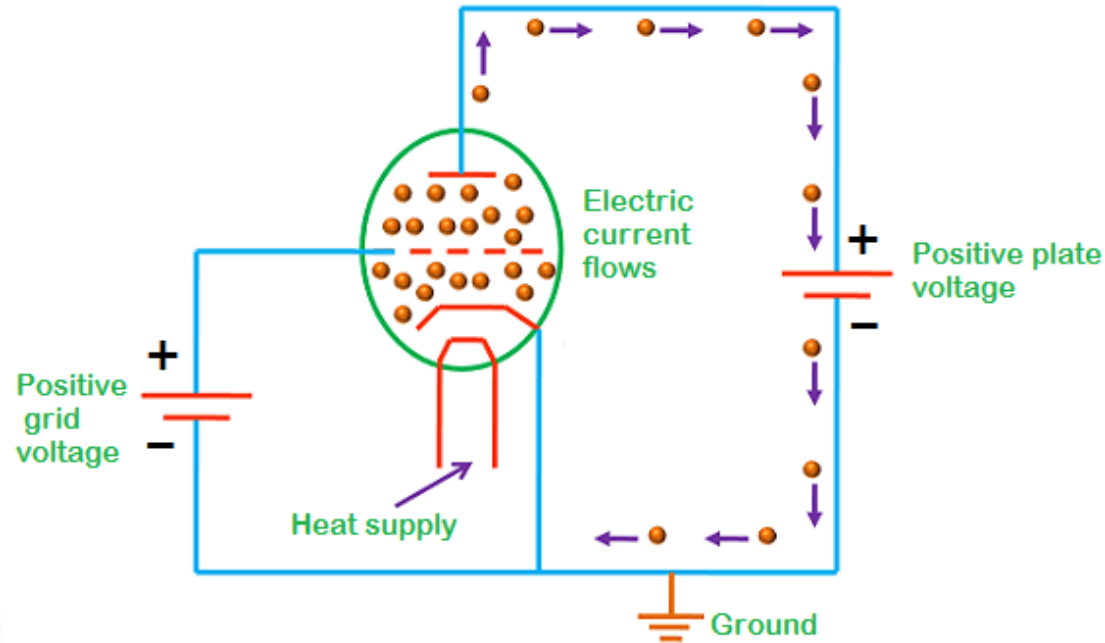
# Vacuum Diode



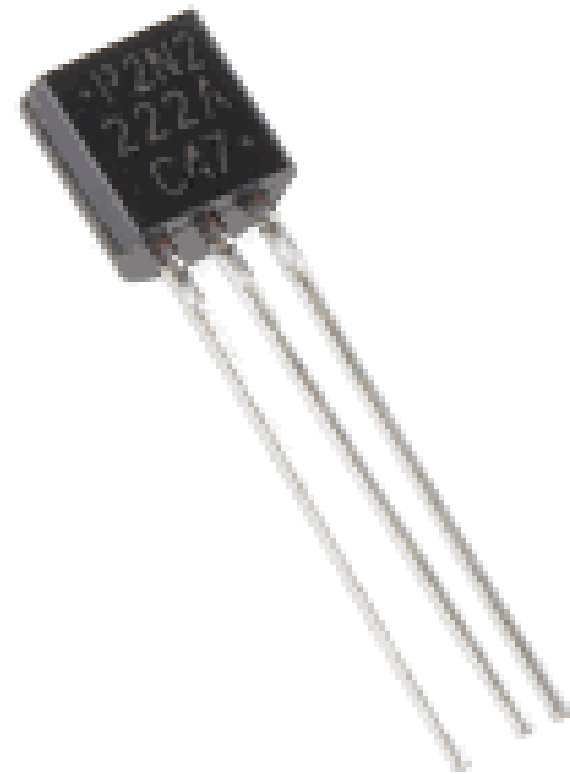
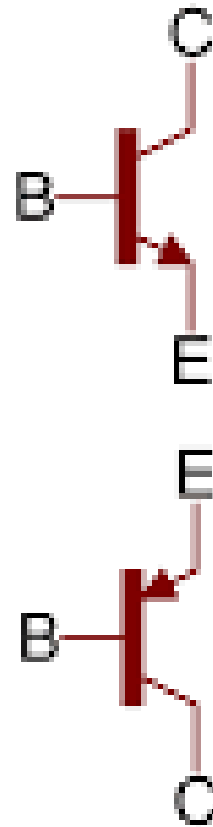
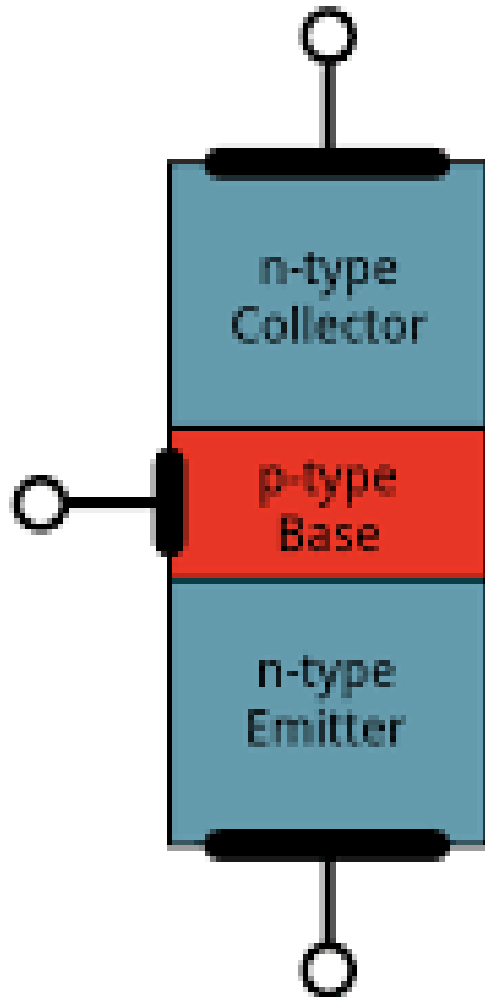
# Vacuum Triode



Vacuum triode with positive grid voltage



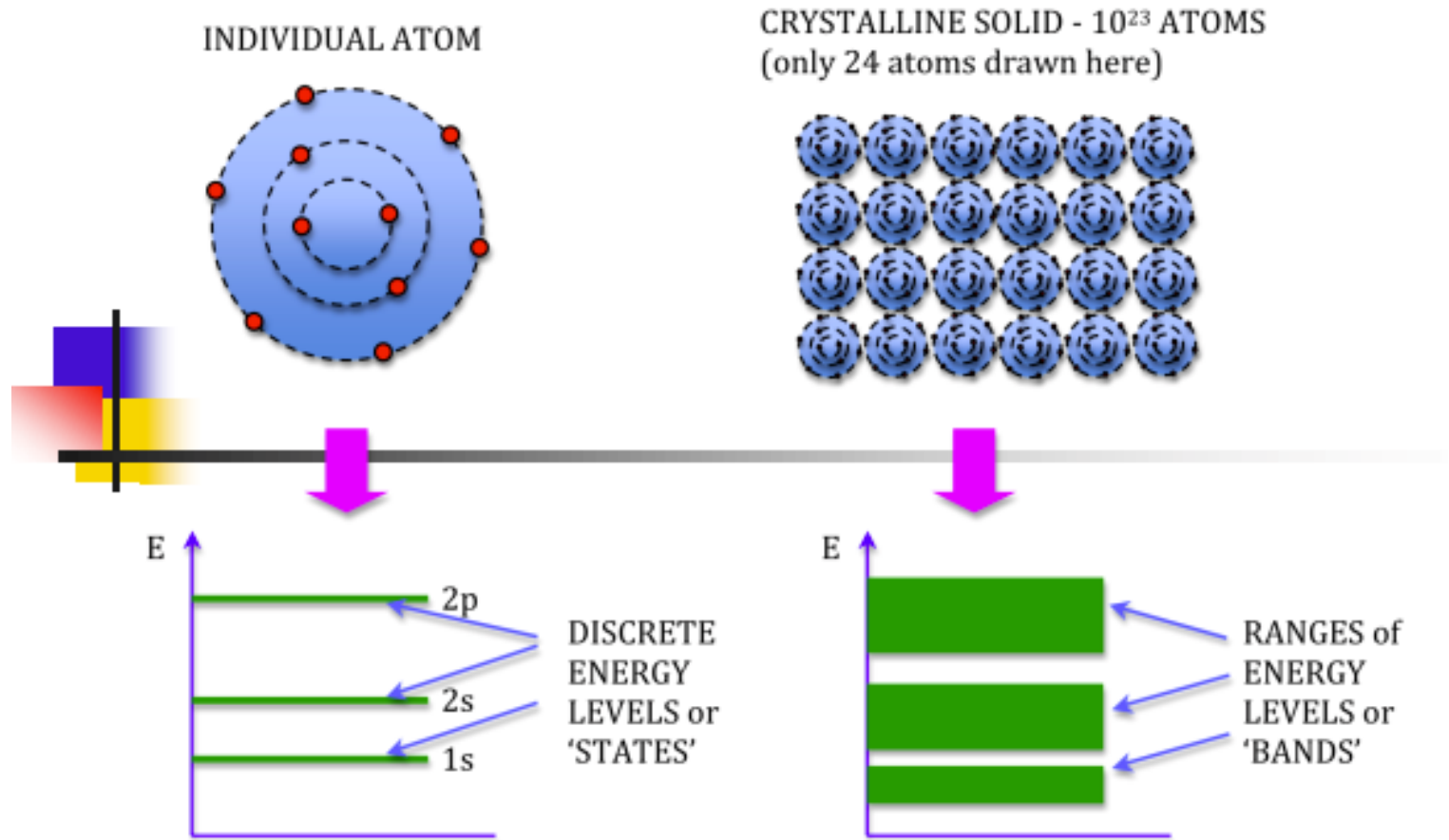
# Transistor



# Integrated Circuit



# Origin of Energy Bands in Crystals

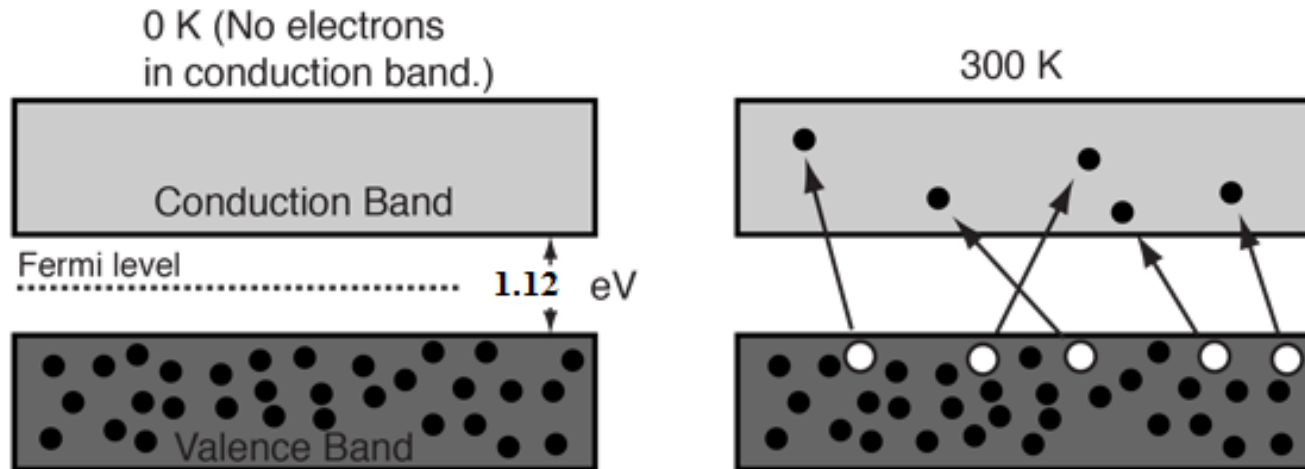


# Metal, Semiconductor and Insulator – Energy Band structure

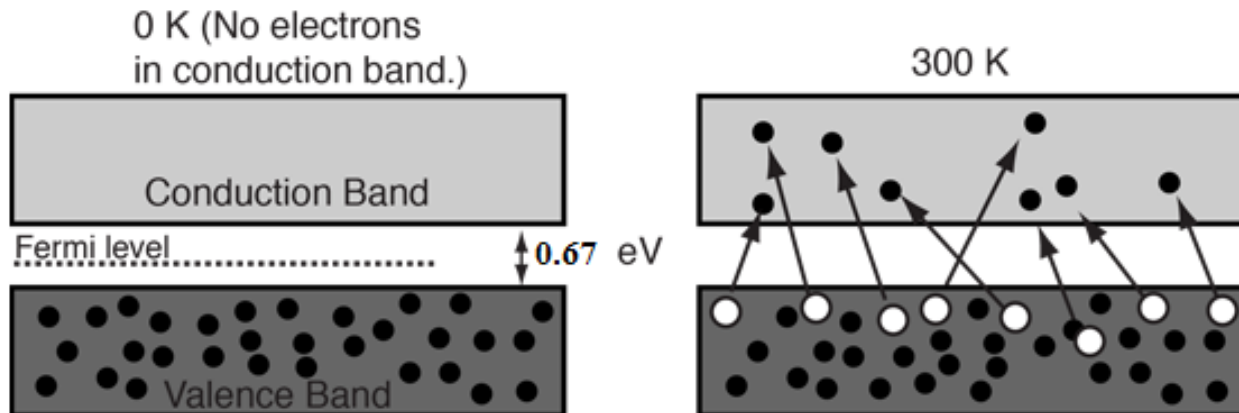


**Normally, band gap of semiconductor  $< 4.0$  eV and insulator  $> 4.0$  eV**

## Silicon Band structure



## Germanium Band structure



***Why Silicon is preferred over Germanium in semiconductor industry although band gap of silicon is more?***



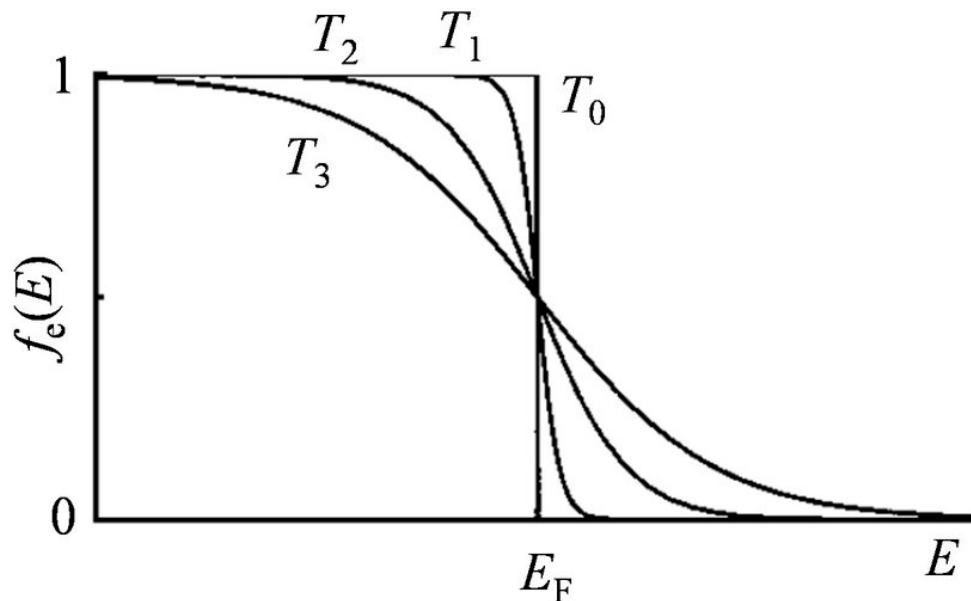
# Fermi Energy

If  $f(E)$  is the probability of occupancy of the state with energy  $E$ :

$$f(E) = \frac{1}{e^{(E - E_F)/kT} + 1}$$

$E_F$  is the Fermi Energy

Explain the symbols



- a. At  $T=0$  K,
  - i.  $f(E) = 1$ , if  $E < E_F$
  - ii.  $f(E) = 0$ , if  $E > E_F$
  
- b. At  $T > 0$  K,  
 $f(E) > 0$  for  $E > E_F$   
When  $E = E_F$ ,  $f(E) = 1/2$

Simple Semiconductor: Si, Ge, C etc.

Compound Semiconductor: SiC (IV-IV), SiGe (IV-IV), GaAs (III-V), nO (II-VI) etc.

Intrinsic (or pure) and Extrinsic (or doped) semiconductor:

**In Intrinsic semiconductor, no. of electrons = no. of holes but in extrinsic semiconductor they are different**

**What is the difference of Intrinsic and Extrinsic semiconductor in terms of conductance at different temperatures?**